PTO/SB/088 (08-00)

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Substitute for form 1449B/PTO	Complete if Known				
Substitute for form 1449B/PTO	Application Number	10/822,345			
INFORMATION DISCLOSURE STATEMENT BY APPLICANT	Filing Date	April 12, 2004			
	First Named Inventor	Meng Tao			
	Group Art Unit	2812-2813			
(use as many sheets as necessary)	Examiner Name	-Not Yot Assigned Colleen E. R			

124263-1019 Attorney Docket Number of 2 Sheet

		OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS	
Examiner Initials*	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	Τ²
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Date Considered	06/18/06

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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				Complete If Known		
Substitute for form 1449B/PTO		Application Number	10/822,345			
INE	ORMATIO	N DIS	CLOSURE	Filing Date	April 12, 2004	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT				First Named Inventor	Meng Tao	
STATEMENT BY APPLICANT				Group Art Unit	2812	
	(use as many s	sheets as ne	ecessary)	Examiner Name	Not Yet Assigned	
Sheet	2 .	of	2	Attorney Docket Number	124283-1019	

	OTHER PRIOR ART – NON PATENT LITERATURE DOCUMENTS	
Examir@ite Initials No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	2
æ	I. LYUBINETSKY, Z. DOHNALEK, W.J. CHOYKE, and J.T. YATES, JR., Cl ₂ dissociation on Si(100)-(2x1): A statistical study by scanning tunneling microscopy, Phys. Rev. B, 1998, 7950, 58	
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Sheet 1 of 1

Complete If Known				
Application Number	10/822,345			
Filing Date	April 12, 2004			
First Named Inventor	Meng TAO			
Art Unit	2813			
Examiner Name	-Unknown Collean E. Rodgers			
Attorney Docket Number	124263-1019			

			U. S. PATENT D	OCUMENTS		
Examiner Cite Initial No.1		Document Number	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figure	
		Number-Kind Code ^{2 to known}			Appear	
(ce)		5,760,462	06-02-1998	Barron et al		
(ce)		5,943,568	08-24-1999	Fujii et al		
(IP)		6,483,172	11-19-2002	Cote et al		
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пина	No.	Country Code ³ Number ⁴ Kind Code ⁸ ^{64 known)}	WIW-50-1111		Figures Appear	+
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